

राष्ट्रीय प्रौद्योगि की संस्थान सिलचर National Institute of Technology Silchar

(राष्ट्रीय महत्व का संस्थान)

(An Institute of National Importance) www.nits.ac.in, Phone: 03842-242914, Fax: 03842-224797, Assam-788010 (INDIA)

Advertisement No.: NITS/Dean-RC/CE/628/01/2023

Date: 14-11-2023

Applications are invited from Indian citizens in the given format for the post of Project Associate I in the Department of Civil Engineering, NIT Silchar, under Research, Education and Training Outreach (REACHOUT) scheme, MOES sponsored project, Govt. of India. The details are mentioned below:

Title of the project	Estimation of Quantitative Precipitation Errors (QPE) in Southern North East Region, India using Radar Data.
Name & address of Sponsoring Agency	Research, Education and Training Outreach (REACHOUT) scheme, MOES.GOI
Name of the Post	Project Associate I
No. of post	02 (Two)
Project Duration	03 years or till Completion of the Project, whichever is earlier (extension of selected candidates would be based on performance review every 12 months)
Name of Principal Investigator with	Dr. Briti Sundar Sil, Department of Civil Engineering, National Institute of
address and email.	Technology Silchar, Silchar, Assam, India, 788010. E-mail: britisil@gmail.com

Other details:

1.	Essential qualifications	Candidates with Master degree (M. Tech/Msc/ME) in the field of Water Resources Engineering						
		or allied fields//Computer Science/Mathematics or any relevant discipline with excellent						
		academic records from reputed recognized Institutes/Universities.						
2.	Desirable Experience	Research/project experience in the field of Water Resources						
		Engineering/Hydrology/meteorology/mathematical modeling/computational modeling or any						
		other area relevant to this research project.						
3.	Age limit	Preferably below 35 Years.						
4.	Salary	Rs. 31,000/- p.m. for candidates with GATE/CSIR-UGC NET qualification.						
		Rs. 25,000/- p.m. for candidates without GATE/CSIR-UGC NET qualification.						
		HRA will be given if Institute Accommodation is not provided.						
5.	Relaxation on	Palayation as par Cout of India Pules						
	qualification and age	Relaxation as per Govt. of India Rules.						
6.	Date of Interview, time,	The interview date and mode (online/offline) and venue (if necessary) will be notified in due						
	and venue	course of time through email.						
7.	How to apply	Applicants are to submit their filled-up applications along with C.V. to the PI accompanying						
		photocopies of all relevant documents with self-attestation to the address: Dr. Briti Sunda						
		Associate Professor, Department of Civil Engineering, National Institute of Technology Silchar,						
		Silchar- 788010, Assam, India. Candidate should write "Application for the post of Project						
		Associate-I under the project Research, Education and Training Outreach (REACHOUT) scheme,						
		MOES." on the top of the envelope. Applicants are also requested to send the soft copy of the						
		duly filled application along with C.V. & all necessary documents to the PI through email						
		(britisil@gmail.com) with the subject as "Application for the post of Project Associate I under						
		the project REACHOUT-MOES" on or before 30-11-2023 .						
8.	Other conditions	No TA/DA will be paid for appearing in the interview and/or joining to the post.						
		All the terms & conditions for this recruitment will be as per the guidelines of the						
		sponsoring agency and NIT Silchar.						
	C-11 (Shortlisted candidates will be intimated through e-mail for interview. Candidates are adv						
9.	Call for interview	Shortlisted candidates will be intimated through e-mail for interview. Candidates are advised to						
9.	Call for interview	Shortlisted candidates will be intimated through e-mail for interview. Candidates are advised to check their emails regularly.						
9.	No objection certificate	l ~						
		check their emails regularly.						
		check their emails regularly. The employed candidate is to submit a No Objection Certificate from his/her employer at the						
10.	No objection certificate	check their emails regularly. The employed candidate is to submit a No Objection Certificate from his/her employer at the time of the interview						
10.	No objection certificate	check their emails regularly. The employed candidate is to submit a No Objection Certificate from his/her employer at the time of the interview The Institute reserves the right to cancel the recruitment without assigning any reason. The						
10.	No objection certificate	check their emails regularly. The employed candidate is to submit a No Objection Certificate from his/her employer at the time of the interview The Institute reserves the right to cancel the recruitment without assigning any reason. The Institute has the discretion to restrict the number of candidates to be short-listed for the						

National Institute of Technology Silchar Format of Application

For Project Associate-I

Paste recent passport size colored photograph

Advertisement No. Dated: Title of the Project-..... Department: 3. Name of the applicant (in block letters): 4. Father's/Husband's Name: 5. Date of Birth (DD/MM/YYYY): 7. Age as on 30th November, 2023 Postal Address: E-mail: Phone no.: 9. Permanent Address: 10. Nationality: 11. Marital Status: 12. Whether belongs to SC/ST/PH/OBC: (If yes, attach certificate): 13. Educational Qualification: (Starting from Class X) Exam. passed Board/ University Division % age of marks/ Year of Subjects CPI passing 10 10+2 Dimploma/BSc. B.E/B.Tech M.Tech/MSc 14. NET/GATE Examinations Passed: I. **NET** II. **GATE**

Subject	Qualifying date	Valid upto	Subject	Score	Valid upto

5.	Details	of employments:					
	Sl. No.	Name of the Organization	Name of the post	Period	Scale of pay and present pay	Nature of duty	

16. 7	Any other relevant	tinformation t	that vou may	like to furnish:
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Declaration

I declare that the above information are true a	d correct to the l	best of my	knowledge and	belief.
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Date:		
Place		Signature of the applicant